

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Mitsugu ABE, et al.

SERIAL NO: 10/549,294

GAU: 3723

FILED: September 16, 2005

EXAMINER: ROSE, R.

FOR: MATERIAL FOR PURIFICATION OF SEMICONDUCTOR POLISHING SLURRY,  
MODULE FOR PURIFICATION OF SEMICONDUCTOR POLISHING SLURRY AND  
PROCESS FOR PRODUCING SEMICONDUCTOR POLISHING SLURRY

REQUEST FOR EXTENSION OF TIME  
UNDER 37 C.F.R. 1.136

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313

SIR:

It is hereby requested that a **one** month extension of time be granted to November 14, 2008 for

☒ filing a response to the Official Action dated: July 14, 2008.

☐ responding to the requirements in the Notice of Allowability dated:

☐ filing the Formal Drawings. The Issue Fee due has been timely filed.

☐ responding to the Notice to File Missing Parts of Application dated:

☐ filing a Notice of Appeal. A timely response to the final rejection, due has been filed.

☐ filing an Appeal Brief. A Notice of Appeal was filed on:

☐ Applicant claims small entity status. See 37 CFR 1.27.

The required fee of \$130.00 is being made by credit card payment online (if electronically filed), or is attached hereto (if paper filed), and any further charges may be made against the Attorney of Record's Deposit Account No. 15-0030.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,  
MAIER & NEUSTADT, P.C.  
Norman F. Oblon



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